



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANTS: Jaekwang CHOI et al. CONF. NO.: 2759
SERIAL NO.: 10/807,139 GROUP: 1763
FILED: March 24, 2004 EXAMINER: George A. GOUDREAU
FOR: SLURRY COMPOSITIONS AND CHEMICAL MECHANICAL
POLISHING METHOD USING THE SAME
DOCKET NO.: 2557-000215/US

AMENDMENT AND RESPONSE IN CONJUNCTION WITH RCE

July 21, 2006

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop RCE

Dear Sir:

Responsive to the Final Office Action (“Action”) dated April 5, 2006, the following amendments and remarks are submitted in connection with the above-referenced application. The sections included in this response are as follows:

Amendments to the Claims begin on **page 2** of this paper; and
a Remarks section begins on **page 15** of this paper.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	37	-	38	=	0
Independent	8	-	5	=	3